	Hits	Search Text	DBs
44	0	<pre>wafer) near20 (expos\$4 or illuminat\$4 or irradiat\$4)) and ((resist or resin or photoresist) same (fluid or solution or liquid</pre>	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

(((stor\$4 near9 device) or container or holder or bath) same (liquid or solvent or solution or ether or (TPM near6 ether) or (\$4propylene near8 glycol near12 ether)) same (remov\$4 or dissolv\$4 or strip\$4 or eliminat\$4) same ((wafer or substrate) near16 (resin\$4 or photoresist or resist) near29 (submers\$4 or immers\$4) near19 (bath or container or holder or storage) near29 (solvent or solution or ether or liquid))) and ((resin or photoresist or resist) near16 (substrate or wafer) near20 (expos\$4 or illuminat\$4 or irradiat\$4)) and ((resist or resin or photoresist) same (fluid or solution or liquid or solvent or strip\$4) same (conductivit\$4 or electric\$4 or conduct\$4 or resistivity or resistance or impedance or capacitance) same (alter\$4 or chang\$4 or increas\$4 or vary\$4 or decrease or variation)) and ((monitor\$4 or determin\$4 or calculat\$4 or measur\$4) same (conductivit\$4 or conductance or capacitance or impedance or resistance or impedance or resistance or electric\$4 or current) same (LED or (light near5 emit\$5 near6 diode) or (visual near9 display) or computer or sensor))	

	Hits	Search Text	DBs
46	0	(((stor\$4 near9 device) or container or holder or bath) same (liquid or solvent or solution or ether or (TPM near6 ether) or (\$4propylene near8 glycol near12 ether)) same (remov\$4 or dissolv\$4 or strip\$4 or eliminat\$4) same ((wafer or substrate) near16 (resin\$4 or photoresist or resist) near29 (submers\$4 or immers\$4) near19 (bath or container or holder or storage) near29 (solvent or solution or ether or liquid))) and ((resin or photoresist or resist) near16 (substrate or wafer) near20 (expos\$4 or illuminat\$4 or irradiat\$4)) and ((resist or resin or photoresist) same (fluid or solution or liquid	US-PGPUB; USPAT; FPRS; EPO; JPO;

47	39	<pre>(conductivit\$4 or electric\$4) same (alter\$4 or chang\$4 or increas\$4 or vary\$4 or decrease or variation) same (monitor\$4 or</pre>	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
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	Hits	Search Text	DBs
48		resistance or electricS4 or	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
49	64	S50 NOT S49	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
50	26	resistance or electric54 or current) same (resin or resist or	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

		(((stor\$4 near9 device) or container or holder or bath) same (liquid or solvent or solution or ether or (TPM near6 ether) or	
		(\$4propylene near8 glycol near12	
		ether)) same (remov\$4 or	
		dissolv\$4 or develop\$4 or	
		solubiliz\$5 or strip\$4) same	US-PGPUB;
		(resin\$4 or photoresist or resist	USPAT; FPRS;
51	36	or polymer\$3) same (conductivit\$4	EPO; JPO;
		or electric\$4 or conduct\$4 or	DERWENT;
		resistivity or resistance or	IBM_TDB
		impedance)) and ((monitor\$4 or	
		determin\$4 or calculat\$4 or	
		measur\$4) same (conductivit\$4 or	
		conductance or impedance or	
		resistance) same ((visual near5	
		display) or computer or (display	
		near9 panel)))	

	Hits	Search Text	DBs
52	73	((liquid or solvent or solution or ether or (TPM near6 ether) or (\$4propylene near8 glycol near12 ether)) same (remov\$4 or dissolv\$4 or develop\$4 or solubiliz\$5 or strip\$4) same (resin\$4 or photoresist or resist or polymer\$3) same (conductivit\$4 or electric\$4 or conduct\$4 or resistivity or resistance or impedance) same (monitor\$4 or determin\$4 or calculat\$4 or measur\$4 or alter\$5 or var\$3 or control\$4) same (conductivit\$4 or conductance or impedance or resistance) same (visual near5 display) or computer or (display near9 panel)))	USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
53	60	S54 NOT S53	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
54	57	S55 NOT S52	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB